

ESCC9000P: a generic specification for space plastic encapsulated microcircuits

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OUTLINE

CONTEXT AND MOTIVATION

ESCCON 2021

ESCC

propean Space Components Coordination

- SCOPE AND OBJECTIVES
- ORGANIZATION
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- - CONTENTS AND TRICKY POINTS
 - CONCLUSION AND PERSPECTIVES

CONTEXT AND MOTIVATION



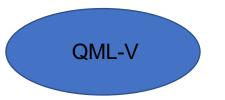
European standard for ceramic, hermetically sealed microcircuits for space applications.



DLA class for ceramic not hermetically sealed devices for space and military aeronautic applications.



A Space quality standard for Plastic Encapsulated Microcircuits in Space Applications



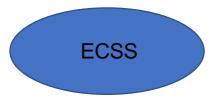
DLA class for hermetically sealed Microcircuits for space applications.



A NASA quality standard for Plastic Encapsulated Microcircuits (PEM).



DLA class for hermetically sealed devices for military aeronautic applications.



A class standard from the European Cooperation for Space Standardization.

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Enhanced Product, packaged devices offered with extended temperature range with additional qualification and characterization

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Enhanced Product, packaged devices offered with extended temperature range with additional qualification and characterization



CONTEXT: AN EXAMPLE OF A COMPARISON OVERVIEW

FLOW CHARTS		CERANIC					PLASTIC									
		HERMETIC					NON-HEAVETHE									
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* Courtesy of Teledyne/E2V

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https://www.teledyne-e2v.com/content/uploads/2018/07/Space_Flows_Comparison_Chart_TE2VSFCC_V1.pdf



SCOPE AND OBJECTIVES (Terms of Reference)

"During the PSWG88, it was decided to create a working group aiming at writing an **ESCC specification for space plastic microcircuits.**

This specification **should be dedicated to high demanding applications (class 1 projects).** This generic specification ESCC9000P should stay close to the ESCC9000: it is just a small adaptation of the ESCC9000 standard to a plastic part. (hermeticity test removal, THB test addition, ...).

In other words, low cost and/or new space applications are excluded from this working group.

This new specification aims at defining the procurement specification of plastic parts with bondings. Flip Chip parts are not in the scope of this Working Group. However, if the specification does not depend on the fact that the part is a flip-chip or a part with bondings, flip chip parts can be incorporated in the scope of this Working Group."





Working Group Membership (at the beginning)

Member	Affiliation	Representing	contact
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Growing interest! with the arrival of new manufacturers!!!

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Schedule (initial one)

- November 2019: kick-off + Comments about the evaluation chart (F4) + TOR approval.
- January 2019: screening chart to be commented.
- March/April 2020: generic specification draft issued
- June 2020: first detailed specification
- September 2020: approval by PSWG. ESCC system ready to qualify the first plastic parts.

But in reality....

- Issue of the generic specification expected by june 2021
- First detailed specifications issued by june 2021: ST Microelectronics and Microchip are the first candidates
- Covid 19 did not help....but the motivation and the participation of the members is remarkable!
- Bimonthly two hours duration meetings are ongoing by january 2021 with limited topics



A dedicated tool: an interactive platform of exchange

https://galaxi.extranet.cnes.fr/sites/DSO Working Group/ESCC9000P/Pages/Home.aspx

Contenu - HOME ×				
Course Course	ESCC9000P Working Group > Contenu > Home PLANNING DU PROJET Autourt est créer La prochaine actualité		wrii 2021	Rechercher dans ce site.
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Which categories are concerned by the generic?

□ Monolithic Microcircuits, wire-bonded, lead frame, plastic encapsulated

Monolithic Microcircuits, wire-bonded, organic substrate, plastic encapsulated

□ Monolithic Microcircuits, flip-chip, organic substrate

Some tricky points....

- Applicability and perimeter of internal visual inspection criteria with respects to the ESCC20400:
 - Analysis performed by each manufacturer
 - Three main optical inspection gates (1st at wafer level, 2nd after sawing, 3rd before molding)
 - Different approaches between small and high volume assembly houses (and even between high volume ones)



And their agreed solutions by the working group....

INTERNAL VISUAL INSPECTION

« ESCC Basic Specification No. 20400 applies on 100% of the die.

Prior to molding/encapsulation, 100% internal visual inspection shall be performed according to ESCC Basic Specification No. 20400.

As an alternative, internal visual inspection shall be performed according to the internal manufacturer specifications (criteria and sampling size). In this case, after encapsulation, a decapsulation strategy must be done on a number of parts according to inspection level AQL S4 with no defect allowed, except those artefacts resulting from the decapsulation process itself. Decapsulation methods according to the ESCC 25300 and/or JESD 22B116 and acceptable artefacts resulting from decapsulation process itself shall be agreed between qualifying agencies and manufacturers. »



Conclusion and Perspectives

- □ The consolidated draft of the generic is expected by june 2021
- □ Next Steps:
 - > Test Methods (CSAM, X rays....) definition and review of their perimeter of applicability
 - Review and matching with respects the charts (In process control, screening, qualification and maintenance of qualification)
- Evaluation standard (ESCC2269000P) to be developped as well
- Enhanced Commercial Qualified Level (ECQL): a further possibility for the manufacturers...

ESCC9000P: a generic specification for space plastic encapsulated microcircuits

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THANKS FOR YOUR ATTENTION!!



THANKS AS WELL TO THE ESCC9000P WG MEMBERS!!!

